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LIST OF REFERENCES CITED BY APPLICANT(S)						7001	
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*EXAMINER INITIAL	DOCUMENT NUMBER	DATE	NAME	<u></u>	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
Mo	5,834,783	11/98	MURAKI ET AL.		250	398	
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415	M. Parikhh, J., Corrections To Proximity Effects in Electron Beam Lithography, App. Phys. 50(g), pp. 4378-4382 (1979)						
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*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy o this form with next communication to applicant.

Sheet_1_ of _1_